

## N-510 High-Force NEXLINE® Z/Tip/Tilt Platform

### Nanometer Precision for Semiconductor Industry, Wafer Alignment



Z, tip, tilt nanopositioning platform with 3 integrated drives (tripod design)

- Self Locking at Rest, No Heat Generation
- Vacuum Compatible and Non-Magnetic Designs Feasible
- Parallel Kinematics for Enhanced Dynamics and Better Multi-Axis Accuracy
- NEXLINE® Piezo Walking Drive Free from Wear and Tear
- Load Capacity 200 N
- High Precision with Integrated 5 nm Incremental Sensors + Picometer Resolution Dithering Mode

| Model                                   | Travel  | Load capacity | Linear velocity | Dimensions                                   |
|---|---|---------------|-----------------|--|
| N-510 NEXLINE®<br>Z, tip, tilt platform | 1,3 mm<br>vertical range<br>10 mrad<br>tilt angle | 200 N         | 0.2 mm/s        | Ø 300 mm (12")<br>clear aperture<br>Ø 250 mm |

## High-Stiffness Nanopositioning Z Stage with NEXLINE® Piezomotors

HIGH-PRECISION VERTICAL POSITIONING, WITH CAPACITIVE FEEDBACK

### N-510K

- Closed-loop resolution to 2 nm
- Self-locking, no heat generation at rest
- Hybrid piezo drive combines high stiffness, long travel and very fast response
- Travel range 400 µm coarse, 40 µm fine
- Direct metrology: One single control loop with capacitive sensors
- Piezo stepping drive w/o wear and tear and outstanding lifetime due to PICMA® piezo actuators



The N-510KHFS Z-stage combines NEXLINE® piezo stepping drives with PICMA® piezo actuators, and meets the strict requirements of inspection tasks in the semiconductor industry. Both drive technologies are controlled by a single control loop based on capacitive position feedback sensors providing accuracy in the nanometer range

|                                  | Travel ranges                 | Max. velocity | Bidir. Repeatability | Max. load | Dimensions                           |
|----------------------------------|-------------------------------|---------------|----------------------|-----------|--------------------------------------|
| N-510KHFS hybrid focusing system | Coarse: 400 µm<br>Fine: 40 µm | 1 mm/s        | 50 nm (full travel)  | 2.5 kg    | Ø external: 300 mm<br>Height 68.5 mm |

# Non-Magnetic Piezo Hexapod

6-AXIS PRECISION POSITIONING SYSTEM WITH NEXLINE® PIEZO STEPPING DRIVES

## N-515K



- For high-energy physics and medical applications
- Travel ranges 10 mm, 6°
- Nonmagnetic
- Load capacity to 50 kg
- Nanometer resolution
- Low Profile: only 140 mm height
- Self-locking, no heat generation at rest

This 6-axis parallel kinematics positioning system with NEXLINE® high-load actuators was designed for use in strong magnetic fields such as are encountered in the vicinity of beam control systems on accelerator rings or in MRI scanners

|  | Travel ranges   | Max. load | Dimensions   |
|--|---|-----------|--|
| N-515KNPH<br>Non-Magnetic<br>Piezo Hexapod | X, Y, Z: 10 mm<br>$\theta_x, \theta_y, \theta_z: 6^\circ$ | 50 kg     | Ø Base plate, external: 380 mm<br>Ø moving platform, top: 300 mm<br>Height: 140 mm<br>Clear aperture: Ø 202 mm |